	Application No.	Applicant(s)
	10/719,090	LEE, CHANG-JUNG
Notice of Allowability	Examiner	Art Unit
	Trinh Vo Dinh	2821
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT Record the Office or upon petition by the applicant. See 37 CFR 1.313	OR REMAINS) CLOSED in the or other appropriate communice. This application is sub-	is application. If not included cation will be mailed in due course. THIS
1. This communication is responsive to amendment filed 05/2	<u>7/05</u> .	
2. The allowed claim(s) is/are 1-6 and 8-19.		
3. The drawings filed on 11/20/03 are accepted by the Examir	ner.	
4. ☐ Acknowledgment is made of a claim for foreign priority un a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: ☐ Applicant has THREE MONTHS FROM THE "MAILING DATE" on the delow. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. ☐ A SUBSTITUTE OATH OR DECLARATION must be submited in INFORMAL PATENT APPLICATION (PTO-152) which give including changes required by the Notice of Draftsperson (a) ☐ including changes required by the attached Examiner's Paper No./Mail Date ☐ (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date ☐ (b) ☐ including such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the composition of the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT Foreign (see 37 CFR 1. DEPOSIT OF	been received. been received in Application I cuments have been received in the suments have been received in the suments have been received in the suments have been received in the sum of this application. Itted. Note the attached EXAM is reason(s) why the oath or do to be submitted. It be submitted. It is application on the sum of the s	No In this national stage application from the reply complying with the requirements INER'S AMENDMENT or NOTICE OF eclaration is deficient. PTO-948) attached the Office action of drawings in the front (not the back) of 1.121(d). IAL must be submitted. Note the
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/06 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sum Paper No./Ma 8), 7. ☐ Examiner's An 8. ☑ Examiner's Sta 9. ☐ Other	mal Patent Application (PTO-152) mary (PTO-413), ail Date nendment/Comment atement of Reasons for Allowance mary Examiner.

Application/Control Number: 10/719,090 Page 2

Art Unit: 2821

REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance:

The cited art of record fails to teach an dipole antenna having first and second radiators forming on the surfaces of a substrate and at least one first metallic layer aligned with the first radiator, and at least one second metallic layer aligned with the second radiator, and the second metallic layer is electrically connected to the second radiator as defined in claims 1 and 11.

Therefore, claims 1-6 and 8-19 are presently allowed.

2. Any comments considered necessary by applicant must be submitted no latter than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Inquiry

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trinh Vo Dinh whose telephone number is (571) 272-1821. The examiner can normally be reached on Monday to Friday from 9:30AM to 6:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong, can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

Application/Control Number: 10/719,090

Page 3

Art Unit: 2821

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Trinh Vo Dinh Art Unit 2821

June 17, 2005